

## Results of Operations

## for the Second Quarter of the Fiscal Year Ending March 31, 2025

## C. Uyemura & Co., Ltd.

Standard Market of the Tokyo Stock Exchange (Stock Code: 4966)

November 11, 2024

### Overview of Consolidated Financial Results **UVEMURA** for the Second Quarter of the Fiscal Year Ending March 31, 2025

Period under review

In Japan (1 company): April–September / Overseas (10 companies): January–June

- Surface Finishing Materials business
  - Both segment sales and profit increased year-over-year due to moderately recovered demand for the mainstay plating chemicals for package PWBs and the yen's depreciation in the foreign exchange market.

### • Surface Finishing Machinery business

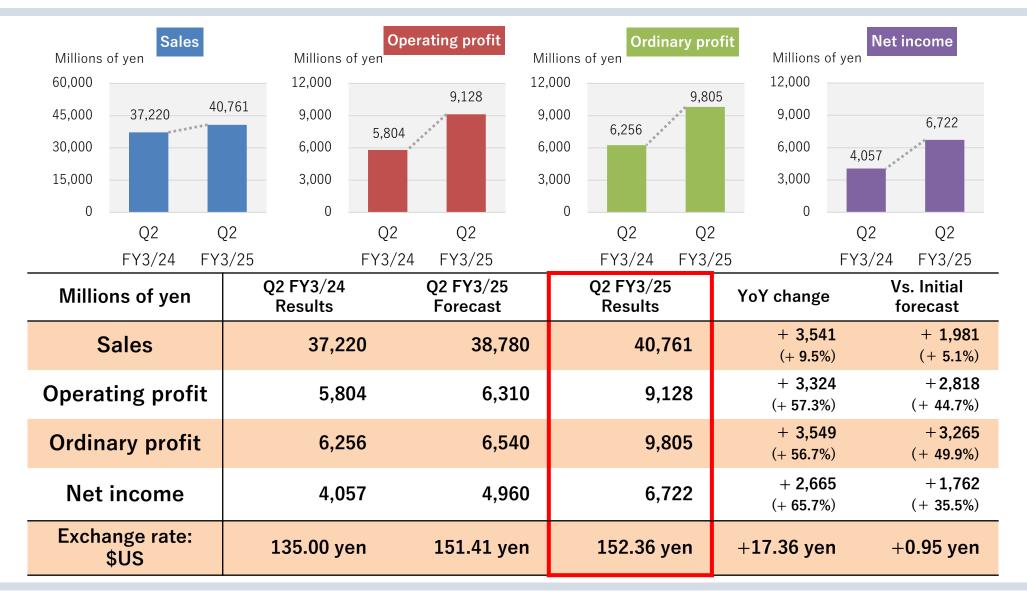
 Both segment sales and profit decreased year-over-year as new capital investments by package substrate manufacturers came to an end.

### Plating Job business

 Although demand for plating processing for automotive parts was sluggish, demand for plating processing for electronic circuit boards increased. In addition, efforts to reduce costs and improve yields resulted in higher sales and improved segment loss from the same period of the previous year.

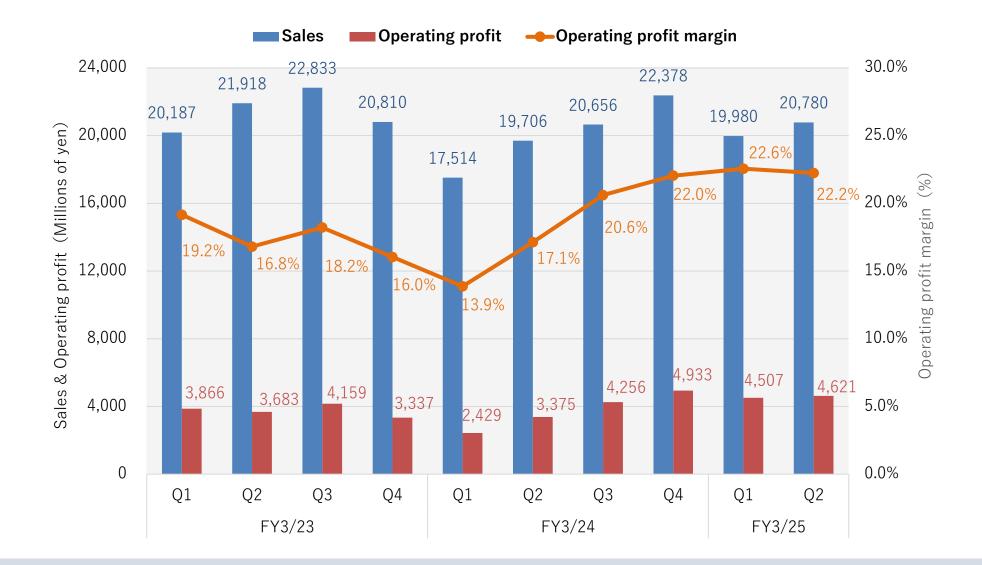


## Q2 FY3/25 Financial Results



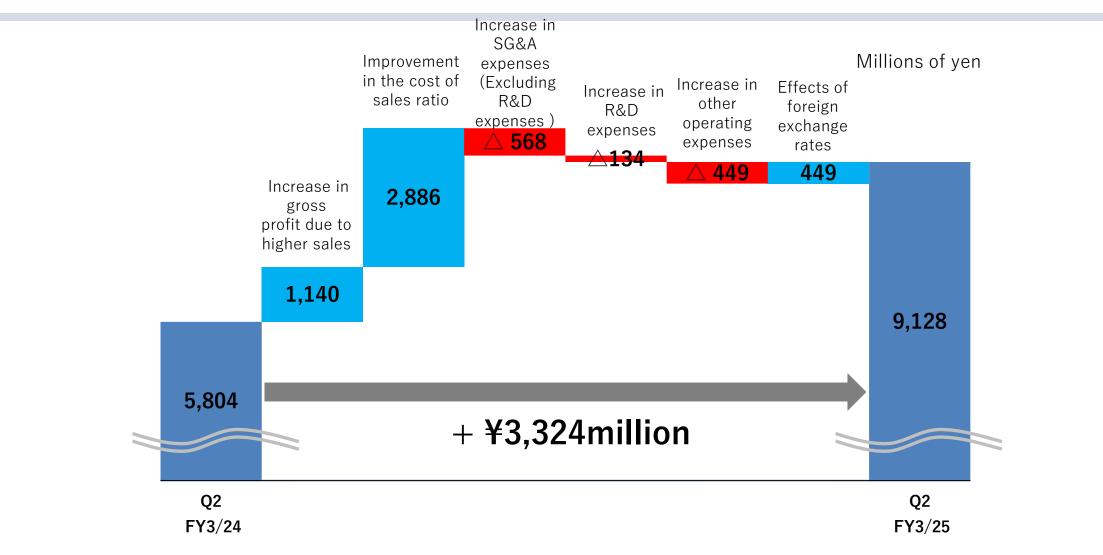


## **Quarterly Results**



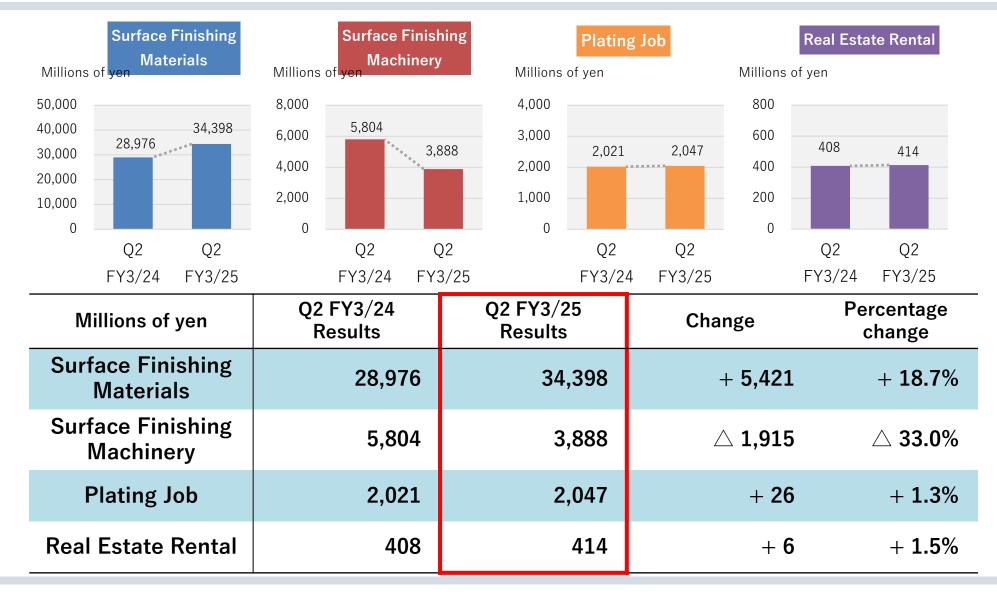


## **Changes in Operating profit**



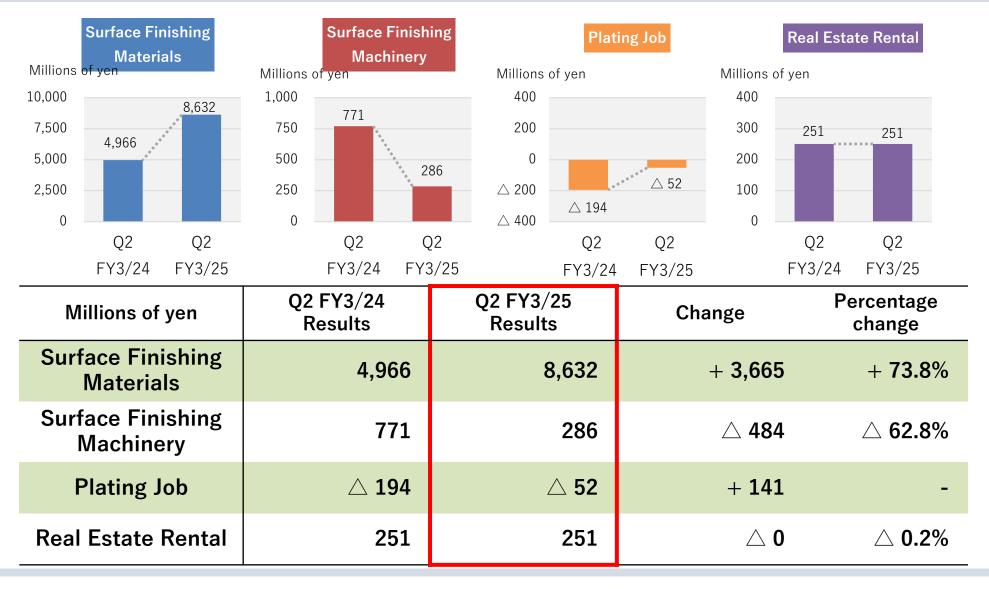


## **Sales by Business Segment**



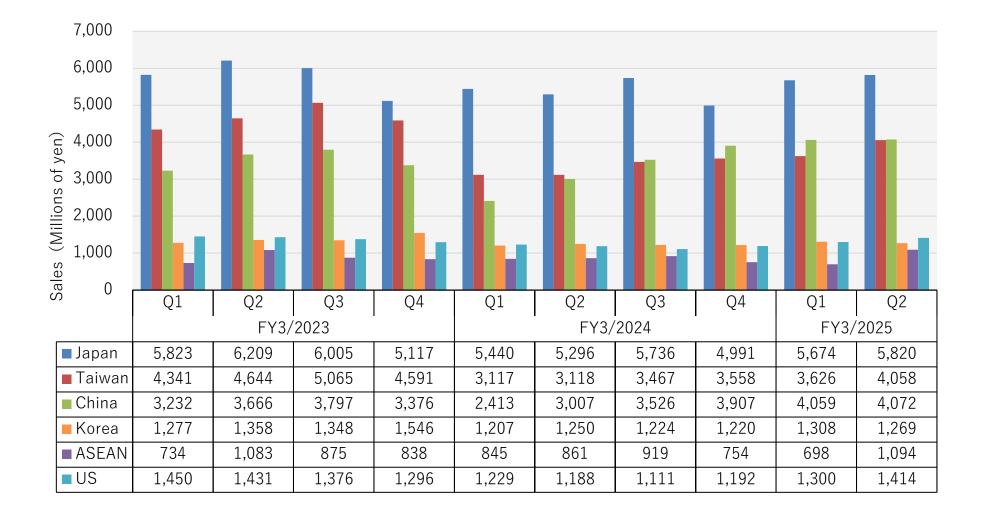


## **Operating Income by Business Segment**



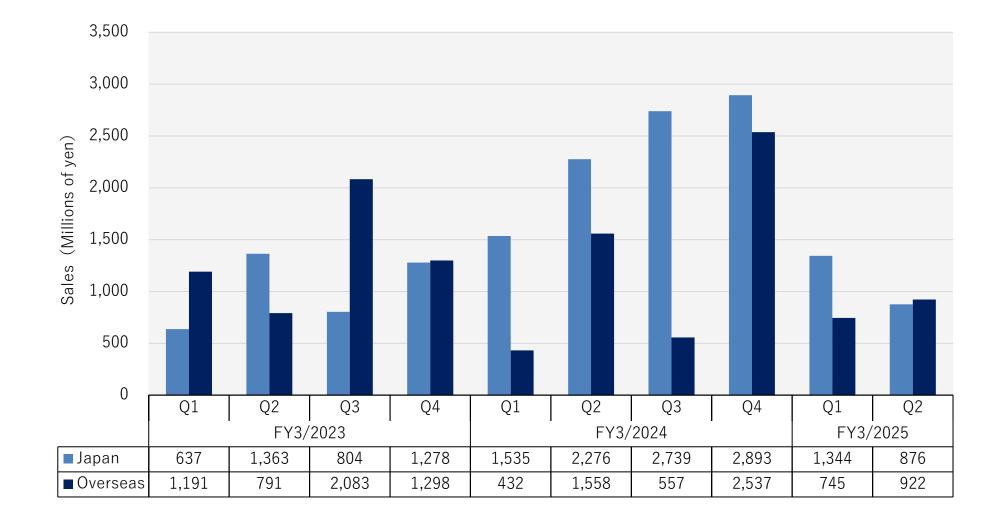


## **Surface Finishing Materials Business Sales**



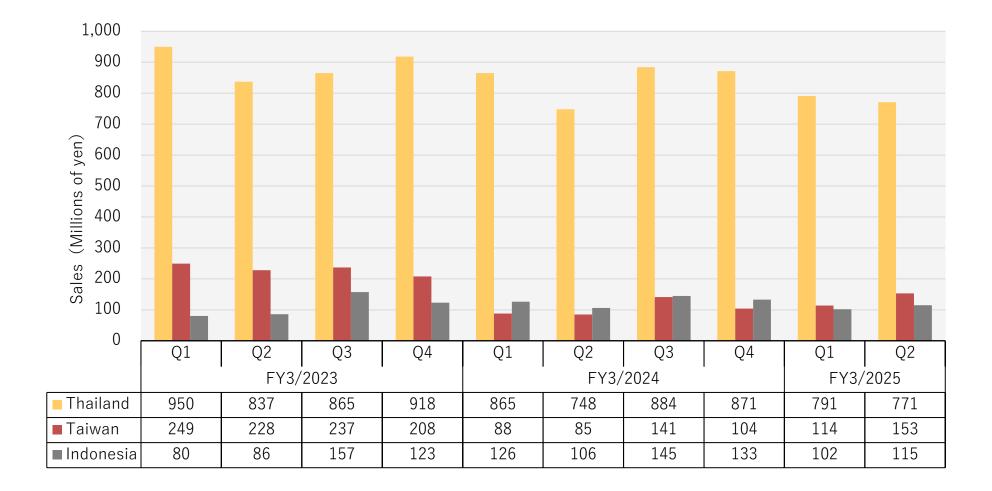


## **Surface Finishing Machinery Business Sales**



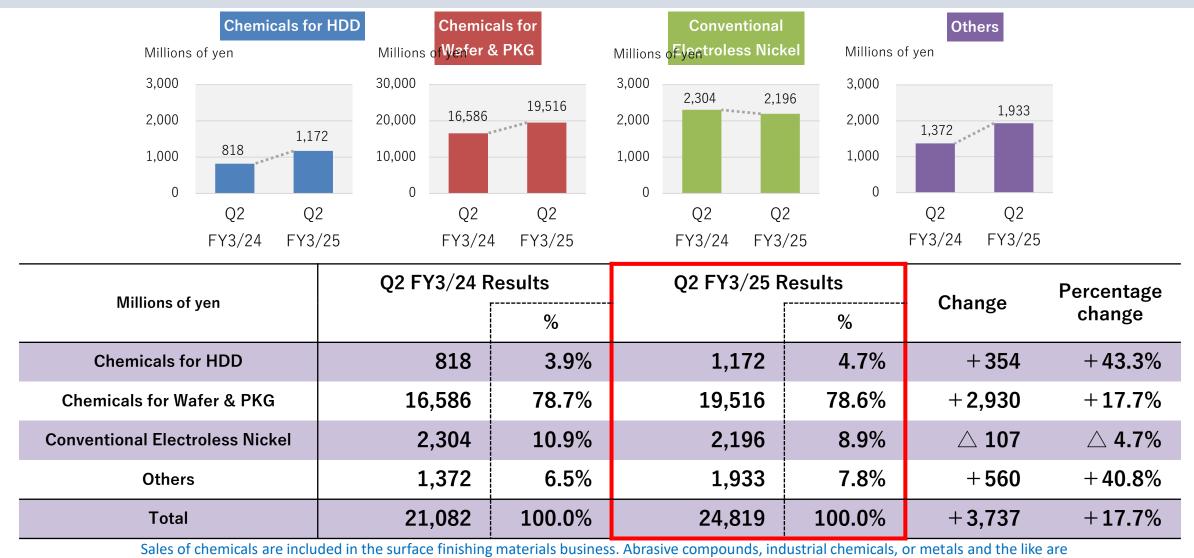


## **Plating Job Business Sales**





## **Sales by Chemicals Categories**

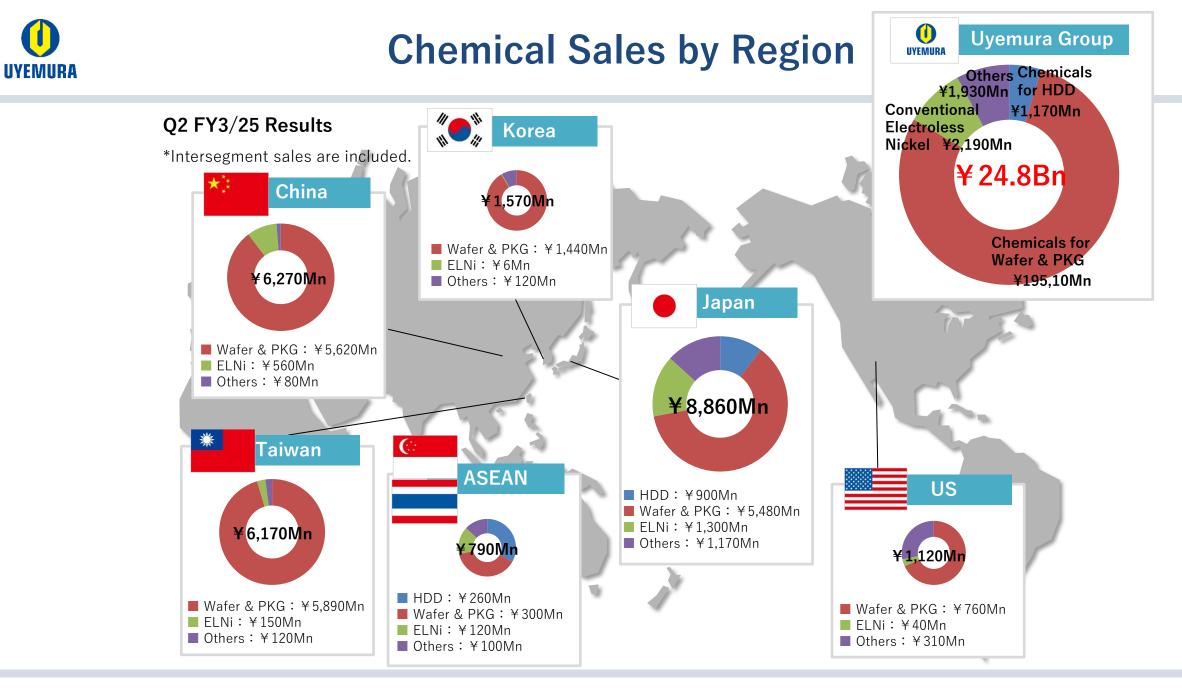


not included in Chemicals categories. \*Intersegment sales are included.



## **Chemicals Business – From Uyemura to End Users**

ra's als	Chemicals for HDD	Chemicals for Wafer & PKG	Conventional Electroless Nickel	Others
Uyemura chemica	<ul> <li>Electroless nickel (high phosphorus type)</li> <li>≥ 12 wt% P content</li> <li>NIMUDEN HDX</li> </ul>	<ul> <li>Surface finishing chemicals Electroless nickel/gold plating Electroless nickel/palladium/ gold plating, etc.</li> <li>Electroless copper plating/ copper electroplating</li> </ul>	<ul> <li>Electroless nickel (medium phosphorus type)</li> <li>8–11 wt% P content</li> <li>NIMUDEN SX, DX, KTY,</li> <li>EL801 (boron type)</li> </ul>	<ul> <li>Decorative plating (nickel/chrome, zinc plating, plastic plating)</li> <li>Solder plating</li> <li>Composite plating chemicals containing PTFE</li> </ul>
Caract eristics	Non-magnetic properties etc.	<ul> <li>High frequency characteristics</li> <li>Soldering reliability etc.</li> </ul>	<ul> <li>Corrosion resistance,</li> <li>Wear resistance etc.</li> </ul>	<ul> <li>Decorativeness, corrosion resistance</li> <li>Wear resistance etc.</li> </ul>
Intermediate product manufacturers	Aluminum magnetic disk manufacturers	Package PWBs manufacturers Semiconductor manufacturers	Various parts manufacturers	Various parts manufacturers
End products	Hard disks (Servers, PCs, etc.)	Products that use semiconductors and electronic components	Automobiles, OA equipment, etc.	Automobiles and others





## **Revisions to the Consolidated Forecast**

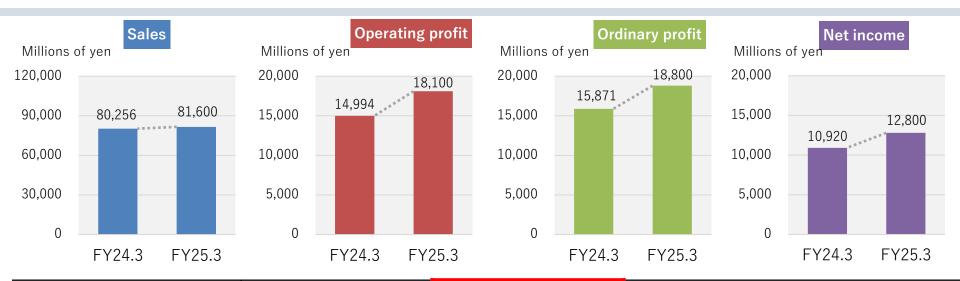
Millions of yen	Previous forecast	Revised forecast	Change	Percentage change
Sales	81,150	81,600	+ 450	+0.6%
Operating profit	13,110	18,100	+4,990	+38.1%
Ordinary profit	13,570	18,800	+5,230	+38.5%
Net income	9,720	12,800	+3,080	+31.7%
Net income per share for the period	599.37 yen	793.73 yen		

< Reasons for Revision of Consolidated Forecast>

There was an increase in production of packages for the artificial intelligence-related market and a recovery in demand for servers for data centers. In addition, demand for in-vehicle power devices was strong due to the electrification and automation of automobiles. As a result, sales of plating chemicals for wafers and package substrates, which are the Group's main products, were strong, and both sales and profits are expected to exceed the previously announced forecast.



## FY3/25 Consolidated Forecast



Millions of yen	FY3/24 Results	FY3/25 Forecast (Revised on Nov.11,2024)Change		Percentage change
Sales	80,256	81,600	+ 1,344	+ 1.7%
Operating profit	14,994	18,100	+ 3,106	+ 20.7%
Ordinary profit	15,871	18,800	+ 2,929	+ 18.5%
Net income	10,920	12,800	+ 1,880	+ 17.2%
Exchange rate: \$US	140.67 yen	151.41 yen	+ 10.74 yen	



## FY3/25 Consolidated Forecasts

### • Sales & Operating profit by Business Segment

	Sales				Operating profit			
Millions of yen	FY3/24 Results	FY3/25 Forecast (Revised on Nov.11,2024)	Q2 FY3/25 Results	Progress against forecast	FY3/24 Results	FY3/25 Forecast (Revised on Nov.11,2024)	Q2 FY3/25 Results	Progress against forecast
Surface Finishing Materials	60,583	68,296	34,398	50.4%	12,477	17,480	8,632	49.4%
Surface Finishing Machinery	14,528	8,193	3,888	47.5%	2,421	386	286	74.1%
Plating Job	4,298	4,329	2,047	47.3%	△ 346	<b>△ 85</b>	<b>∆ 52</b>	-
Real Estate Rental	824	815	414	50.8%	422	384	251	65.4%

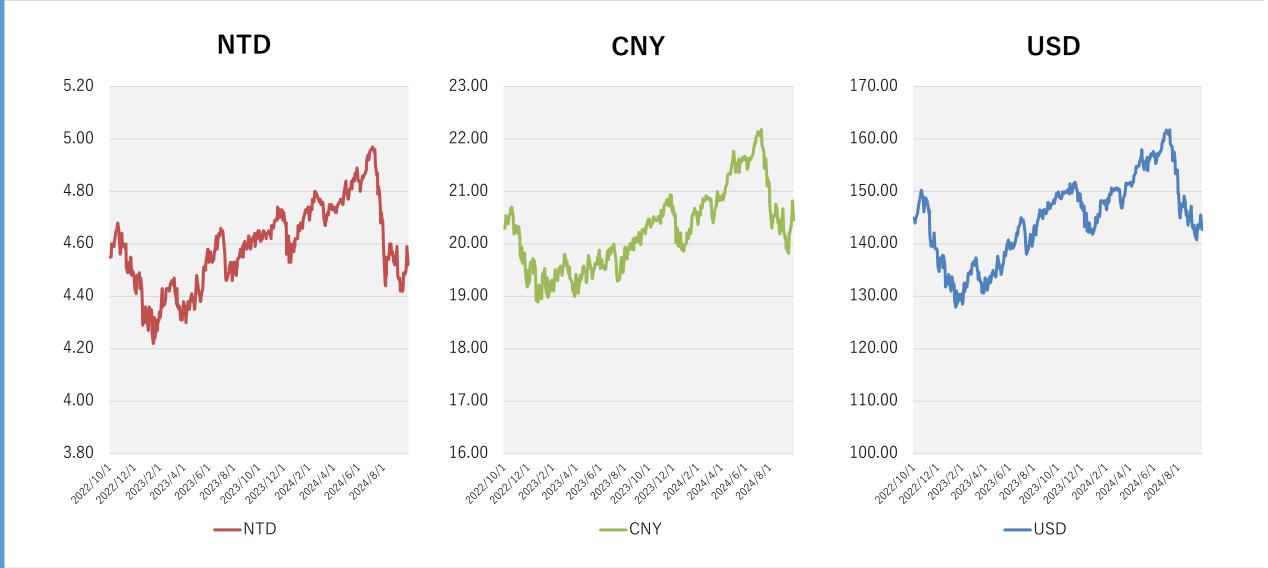
### • Sales by Chemicals Categories

Millions of yen	FY3/24 Results	FY3/25 Forecast (Revised on Nov.11,2024)	Q2 FY3/25 Results	Progress against forecast
Chemicals for HDD	1,772	2,600	1,172	45.1%
Chemicals for Wafer & PKG	36,153	40,000	19,516	48.8%
Conventional Electroless Nickel	4,796	4,400	2,196	49.9%
Others	3,253	3,855	1,933	50.1%
Total	45,975	50,855	24,819	48.8%

<Reference> Foreign exchange sensitivity Assumed rate for fiscal year ending March 31, 2025: 151.41 yen (JPY/USD) Impact on full-year results: If the yen depreciates by 1 yen • Sales: increase by approx. ¥370 million • Operating profit: increase by approx. ¥70 million If the yen appreciates by 1 yen • Sales: decrease by approx. ¥370 million • Operating profit: decrease by approx. ¥70 million • Operating profit: decrease by approx. ¥70 million

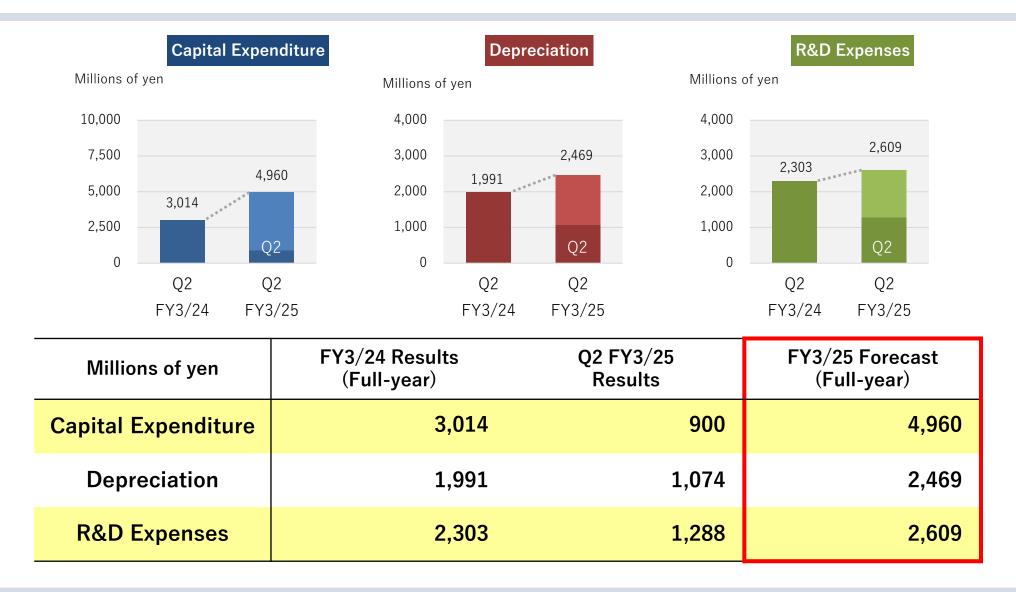


## **Exchange Rates**



### 2024/11/11

## **Capital Expenditure, Depreciation and R&D Expenses**





## **Dividend policy**

Uyemura's basic policy for dividends is to maintain stable dividends in line with business performance.

Dividend per share: Maintain at no less than 2000 yen

- Realization of stable dividends by setting forth a minimum dividend amount
- Enhancement of R&D facilities and expansion of investment in the semiconductor field that links to improvement of corporate value

## **UVENURA** Topic: Progress of the Hirakata Plant Reconstruction

### Plan for additional chemical plant (Hirakata-shi, Osaka)

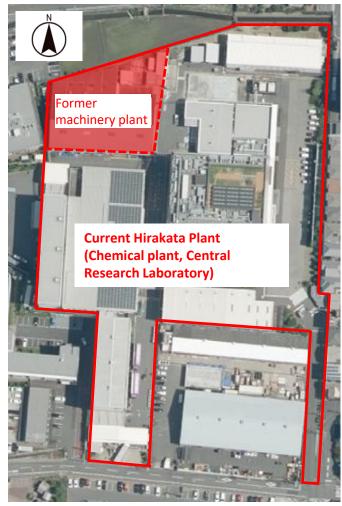
We relocated a machinery plant, which was located on the site of our Hirakata factory, to a nearby site in November 2023. Going forward, we plan to demolish the building in the old machinery factory area and build a new chemical product factory. We will work to expand our chemical production capacity in preparation for increased demand in the semiconductor field.

### Outline of the plan for additional chemical plant

- Steel frame construction / Three stories above the ground
- Building area: 1,450 m<sup>2</sup> (total area: 3,500 m<sup>2</sup>)
- Planned Investment: Approx. 2.1 billion yen
- Scheduled for completion at the end of December 2027

### Future plan

- Demolition of the administration building and construction of the new research building No. 3
- Refurbishment of the existing chemical plant
- Remodeling of the product warehouses



An aerial photo taken by the Geospatial Information Authority of Japan, modified by Uyemura

## UNIT TOPIC: Capital Investment at the South Korean Subsidiary

### Promoting initiatives to improve production efficiency and quality

Our South Korean consolidated subsidiary (Uyemura Korea Co., Ltd.), about 13 years after the establishment of the plant in 2011, has worked to improve production efficiency and stabilize quality by modifying manufacturing facilities, improving the laboratory environment, promoting automation, and introducing next-generation equipment, etc., so to meet customer needs and to reduce costs.

### Main areas of the investment (FY3/25)

- Modification of the manufacturing facilities
  - Stabilizing quality of strong-alkaline products
- Improvement of the laboratory environment
   Updating aging equipment and securing more space for experiments
- Introduction of IBC/DRUM automatic filling facilities - Automating filling work
- Installation of vertical transfer continuous plating equipment
   Enhancing technical support for customers

### Investment amount (FY3/25)

Approx. 2.5 billion won (≈ 280 million yen)

### Uyemura Korea Co., Ltd. (Hwaseong, Gyeonggi-do)







## **Business Environment**

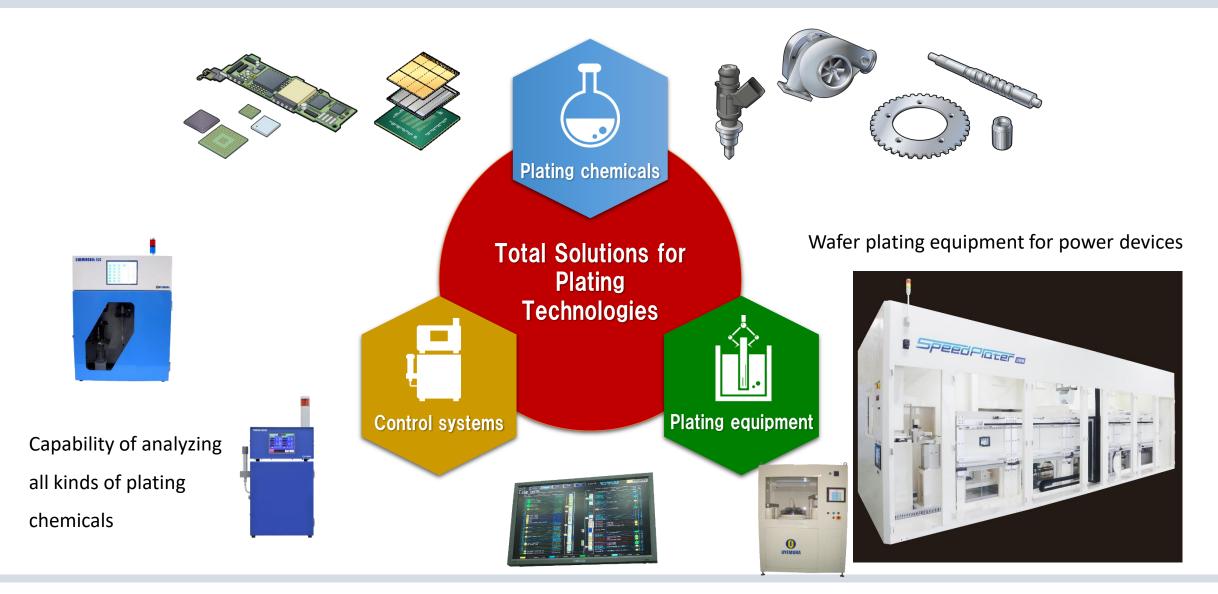


## We aim for higher customer satisfaction We are committed to action with sincerity

- Sales and development strategies that accelerate the growth of our share in markets where it is already high
- Sales and development strategies that increase our share in markets where it is still low
- Manufacturing strategy aligned with market trend
- Provision of total solutions including chemicals, machines and control systems



## **Basic Strategy for Sales**



### 2024/11/11



## **Business Environment**

### Current market condition

- 1. Domestic market: Strong demand for PCs, telecommunications, and power devices. Sales of hard disks are on a recovery trend. Server-related products are on a gradual recovery trend, although it varies depending on the target field of end users.
- 2. Overseas market: Almost similar trend as the domestic market including demand for automobiles

### Technologies we are currently focusing on

Next-generation package technology, substrate technology for telecommunication, car electronics technology, and environment-related technologies

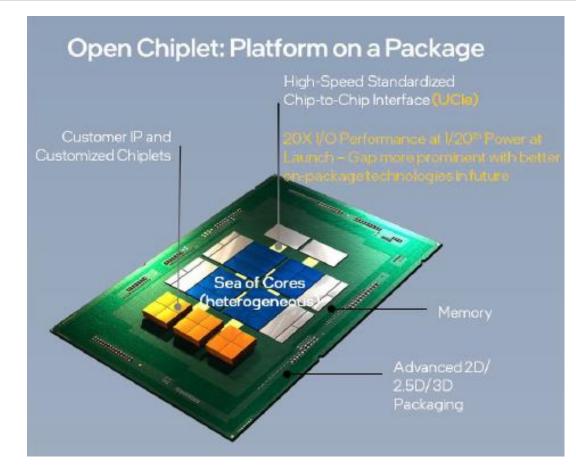
### Fechnologies we should focus on going forward

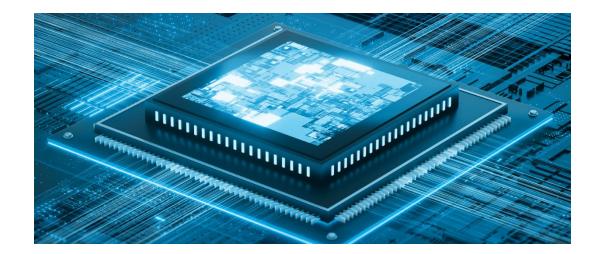
Wiring technology and bump bonding technology for advanced package

Surface finishing technology for next-generation bonding materials and environment-friendly total technology development



## **Technology Required for Advanced Package**



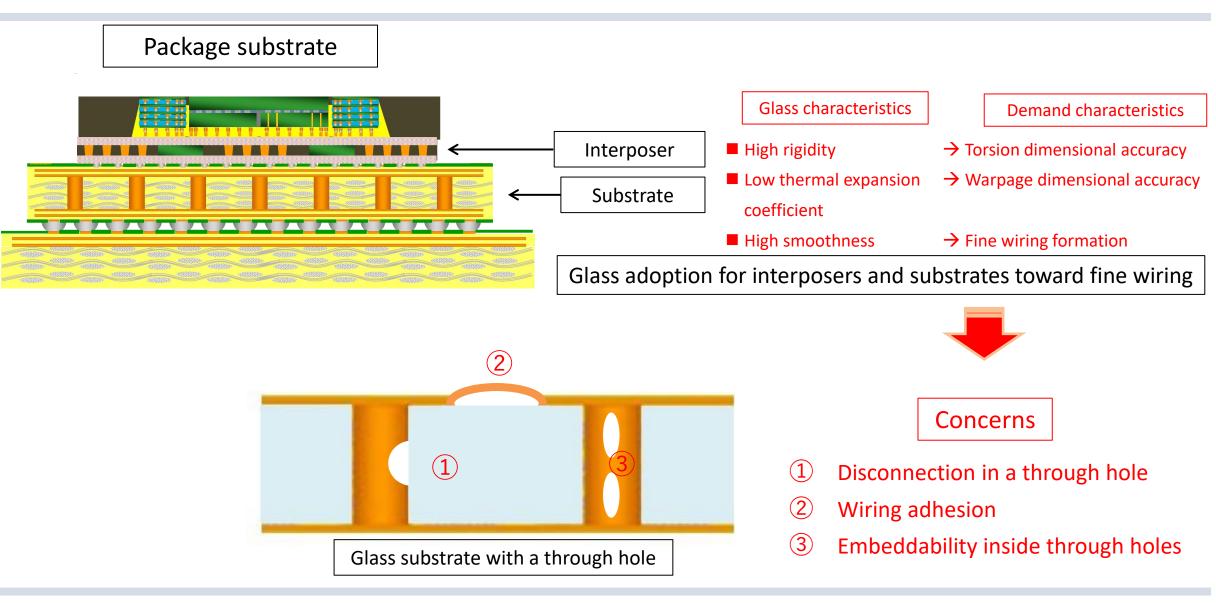


ASRA (Advanced SoC Research for Automotive): Advanced SoC Research for Automotive website, asra.jp

1) Introducing high-reliability base materials
 2) Making progress in high-reliability bonding technology
 3) Taking on a challenge of power consumption reduction

Universal Chiplet Interconnect Express (UCle): Building an open ecosystem, UCle, March 2022

### **O** UYEMURA Possibility of Glass-core Application to Advanced Package



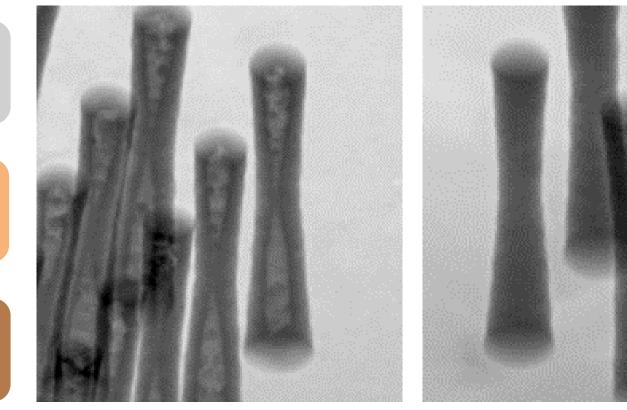


## Proposal of Seed Layer for Glass Core and TH Filling Electrolytic Cu

### MOSL (Metal Oxide Seed Layer)

### Electroless Cu (Seed for Electrolytic Cu)

### Electrolytic Cu (TH Filling)

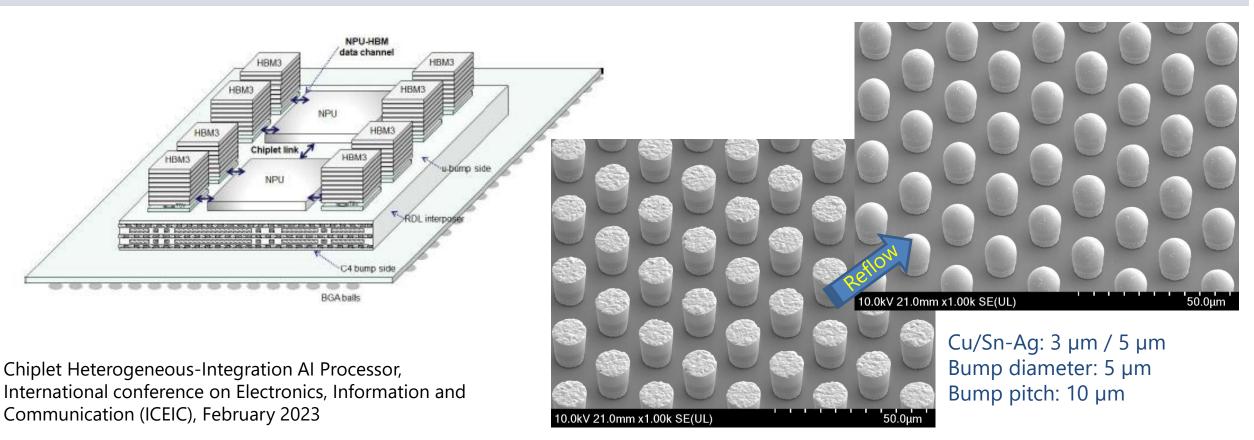


### Old electrolytic Cu

### New electrolytic Cu

TGV opening diameter	100 μm
TGV center diameter	70 µm
Board thickness	600 μm
Board thickness	600 μm

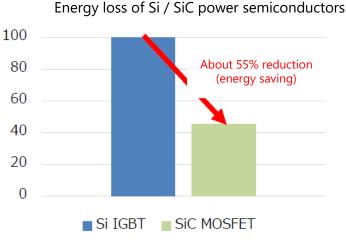
# Proposal of Bump Formation Technology for Advanced Package



New Energy and Industrial Technology Development Organization (NEDO) Research and Development Project of the Enhanced Infrastructures for Post-5G Information and Communication Systems (JPNP20017)

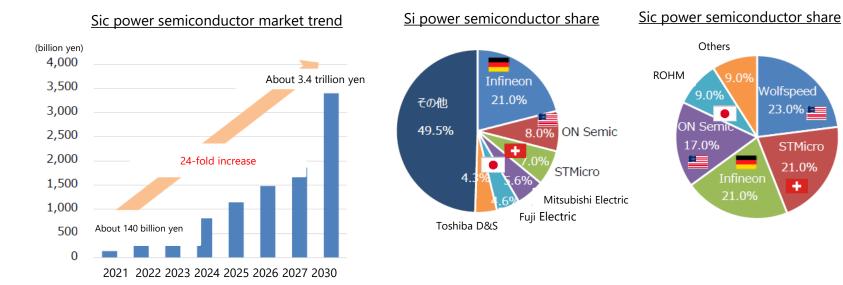


## **Technology Required for Next-generation Power Semiconductors**



Assumed application is inverters for rail vehicles

Vertical axis (energy loss) is 100 for Si power semiconductors



Source: Current Status and Future of Semiconductor and Digital Industry Strategy, published by METI on November 29, 2023

### SiC features

1) Power loss reduction

- 2) High operating temperature
- 3) High speed switching motion
- 4) High heat dissipation effect

### Materials for high operating temperature

 $\rightarrow$  Sintering materials, encapsulation materials, surface finishing, etc.

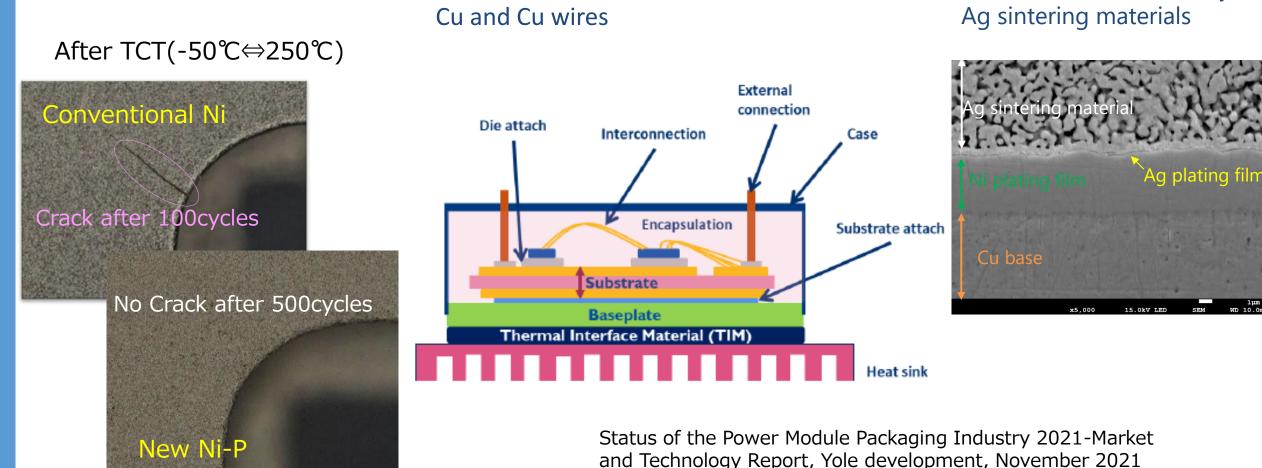
Wolfspeed

23.0%

STMicro

21.0%

Proposal for the Development of Processes Appropriate for New Bonding Materials (Ag sintering, Cu sintering, Cu wires )



Direct electroless Cu plating on Al with excellent bondability for sintered Cu and Cu wires

Ag film formation with excellent bondability for Ag sintering materials

2024/11/11

Ni-P film formation with

excellent heat-crack resistance



## **ESG and SDG Related Initiatives**







## Environmentally Friendly Products: Proactive approach to SDGs



### 1. Pb-free plating bath

- Electroless Ni plating bath mainly for general bathes.
- Pb-free electro Sn plating bath, such as pure Sn and Sn-Ag bath for electronic parts
- 2. Cyan-free bath
  - Electroless Au plating bath with no supply of cyanide-free and fee cyanide for wafers and electronic parts.
- 3. Desmear-free process
  - Process without the use of dangerous permanganate for substrates
- 4. Formalin-free bath and process without the use of formalin
  - Development of formalin-free electroless Cu bath for wafers
- 5. PFOS-free bath and PFOA-free bath
  - PTFE composite plating mainly for automobile parts
- 6. Wastewater treatment
  - Plating solution recycle unit
- 7.  $CO_2$  reduction
  - Low-melting-point bonding material plating and final surface finishing suitable for low-melting-point bonding





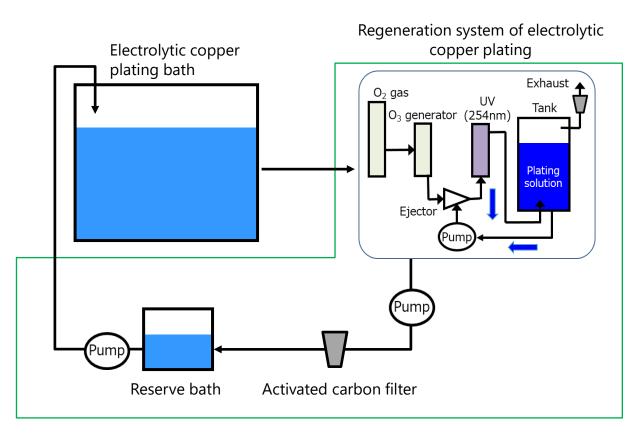




# Proposal for the Reduction in Wastewater through a Regeneration System of Electrolytic Copper Plating Bath



### Illustrative image of electrolytic copper plating regeneration system



### Conventional

Electrolytic copper plating solution is totally waste after a certain period of use due to waste accumulation

### New proposal

Overall performance of plating solution is constant with a regeneration system that decomposes a part of plating solution and removes waste

 $\rightarrow$  Semi-permanent plating solution life

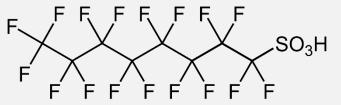




<u>REACH (Registration, Evaluation,</u> <u>Authorization and Restrictions of Chemicals)</u>

PFAS : Per- and PolyFluoroAlkyl Substances

PFOS : perfluorooctanesulfonic acid



2019~ PFOA free type NIMUFLON, NIMUFLON FUL (Type JB)

2024~ PFAS free type

NIMUFLON FUL (FPR-1) (under development)

2011~ PFOS free type NIMUFLON, NIMUFLON FUL (Type B) PFOA : perfluorooctanoic acid

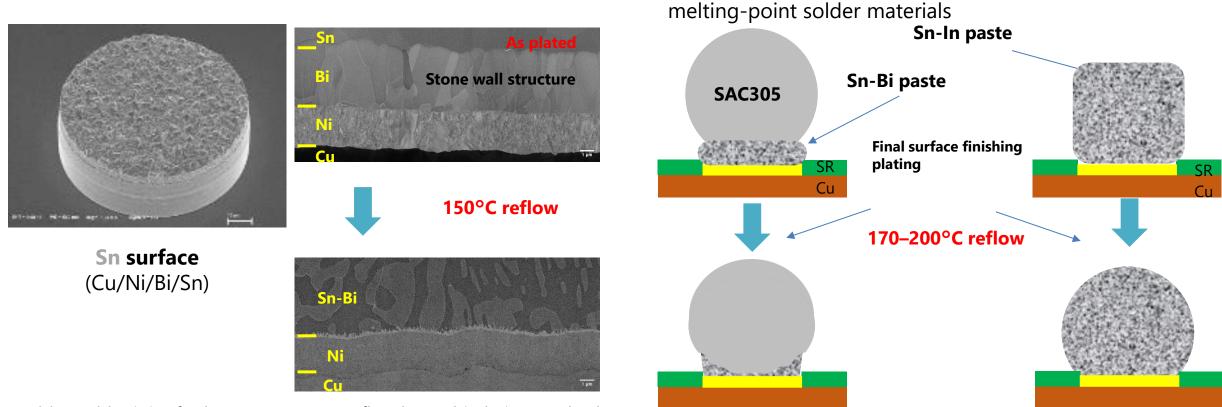


# Proposal of Low-melting-point Solder Bonding Technology

2) Examination of final surface finishing suitable for low-

Low-melting point  $\rightarrow$  Power saving  $\rightarrow$  CO<sub>2</sub> reduction

1) Bump plating for low-melting- point solder materials



Solder/solder joint for low temperature reflow by multi plating method, Wafer-level Packaging Symposium, January 2023



## **Uyemura Group Companies**

Company name	Foundation	Location	Business
C.Uyemura & Co., Ltd.	1848 (Establishment) 1933 (Incorporated)	Japan	🚳 🖪 😫 🗱 🔳
Uyemura International Corporation	1985	US	🚳 🔼 🗐
Uyemura International (Hong Kong) Co., Ltd.	1986	China (Hong Kong)	
Taiwan Uyemura Co., Ltd.	1987	Taiwan	🐼 🔼 🗐 🗱 🎸
Sum Hitechs Co., Ltd.	1987	Thailand	🐼 🔼 🗐 🛃
Uyemura (Shenzhen) Co., Ltd.	1988	China (Shenzhen)	🐼 🖪 🖹 😣
Uyemura International (Singapore) Pte Ltd	1992	Singapore	
Uyemura (Malaysia) Sdn. Bhd.	1996	Malaysia	
Uyemura (Shanghai) Co., Ltd.	2002	China (Shanghai)	
Uyemura Korea Co., Ltd.	2010	Korea	
PT.Uyemura Indonesia	2012	Indonesia	
Sales R&D E Chemica			b Real Estate Rental

2024/11/11

Forecasts of future performance in this report are based on assumptions judged to be valid and information currently available to the Company, but are not promises by the Company regarding future performance. Actual results are affected by various factors and may differ substantially.

# Growing together with ()



### **Uyemura Group Companies**

- Japan
- Hong Kong
- Shenzhen
- Shanghai

- - Uyemura Korea Co., Ltd.
  - Singapore
  - Malaysia

    - PT. Uyemura Indonesia

- C.Uyemura & Co., Ltd. • USA
  - Uyemura International Corporation
  - Uyemura International (Hong Kong) Co., Ltd
  - Uyemura (Shenzhen) Co., Ltd.
    - Uyemura (Shanghai) Co., Ltd.
- Taiwan Korea
  - Taiwan Uyemura Co., Ltd.

    - Uyemura International (Singapore) Pte Ltd
    - Uyemura (Malaysia) Sdn. Bhd.
  - Sum Hitechs Co., Ltd. • Thailand
  - Indonesia